

ORGANIC OPTOELECTRONIC DEVICES AND APPLICATIONS THEREOF**Field of the Invention**

The present invention relates to organic optoelectronic devices and, in particular, to organic photovoltaic devices.

Background of the Invention

Optoelectronic devices using organic materials are becoming increasingly desirable in a wide variety of applications for a number of reasons. Materials used to construct organic optoelectronic devices are relatively inexpensive in comparison to their inorganic counterparts thereby providing cost advantages over optoelectronic devices produced with inorganic materials. Moreover, organic materials provide desirable physical properties, such as flexibility, permitting their use in applications unsuitable for rigid materials. Examples of organic optoelectronic devices comprise organic photovoltaic cells, organic light emitting devices (OLEDs), and organic photodetectors.

Photovoltaic devices convert electromagnetic radiation into electricity by producing a photo-generated current when connected across a load and exposed to light. The electrical power generated by photovoltaic cells can be used in many applications including lighting, heating, battery charging, and powering devices requiring electrical energy.

When irradiated under an infinite load, a photovoltaic device produces its maximum possible voltage, the open circuit voltage or V_{oc} . When irradiated with its electrical contacts shorted, a photovoltaic device produces its maximum current, I_{sc} or short circuit current. Under operating conditions, a photovoltaic device is connected to a finite load, and the electrical power output is equal to the product of the current and voltage. The maximum power generated by a photovoltaic device cannot exceed the product of V_{oc} and I_{sc} . When the load value is optimized for maximum power generation, the current and voltage have the values I_{max} and V_{max} respectively.

A key characteristic in evaluating a photovoltaic cell's performance is the fill factor, ff . The fill factor is the ratio of the photovoltaic cell's actual power to its power if both current and voltage were at their maxima. The fill factor of a photovoltaic cell is provided according to equation (1).

$$ff = (I_{max} V_{max}) / (I_{sc} V_{oc}) \quad (1)$$

The fill factor of a photovoltaic is always less than 1, as I_{sc} and V_{oc} are never obtained simultaneously under operating conditions. Nevertheless, as the fill factor approaches a value of 1, a device demonstrates less internal resistance and, therefore, delivers a greater percentage of electrical power to the load under optimal conditions.

Photovoltaic devices may additionally be characterized by their efficiency of converting electromagnetic energy into electrical energy. The conversion efficiency, η_p , of a photovoltaic device is provided according to equation (2) where P_{inc} is the power of the light incident on the photovoltaic.

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$$\eta_p = \frac{I_{sc} V_{oc}}{P_{inc}} \quad (2)$$

Devices utilizing crystalline or amorphous silicon dominate commercial applications, and some have achieved efficiencies of 23% or greater. However, efficient crystalline-based devices, especially of large surface area, are difficult and expensive to produce due to the problems in fabricating large crystals free from crystalline defects that promote exciton recombination. Commercially available amorphous silicon photovoltaic cells demonstrate efficiencies ranging from about 4 to 12%.

Constructing organic photovoltaic devices having efficiencies comparable to inorganic devices poses a technical challenge. Some organic photovoltaic devices demonstrate efficiencies on the order of 1% or less. The low efficiencies displayed in organic photovoltaic devices results from a severe length scale mismatch between exciton diffusion length (L_D) and organic layer thickness. In order to have efficient absorption of visible electromagnetic radiation, an organic film must have a thickness of about 500 nm. This thickness greatly exceeds exciton diffusion length which is typically about 50 nm, often resulting in exciton recombination.

It would be desirable to provide organic photovoltaic devices which display increased efficiencies in converting electromagnetic energy into electrical energy. In view of the advantages of organic optoelectronic devices discussed herein, it would be desirable to provide organic photovoltaic devices that provide efficiencies comparable to and, in some cases, greater than inorganic photovoltaic devices.

25 **Summary**

The present invention provides organic optoelectronic devices, including organic photovoltaic devices, having a fiber structure and methods of making the same.

In an embodiment, the present invention provides an optoelectronic device comprising a fiber core, a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode, and a second electrode surrounding the organic layer and electrically connected to the organic layer. In some embodiments, the optoelectronic device comprises a photovoltaic cell.

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In another embodiment, the present invention provides an optoelectronic device comprising at least one pixel comprising at least one photovoltaic cell, the photovoltaic cell comprising a fiber core, a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer surrounding the first electrode and electrically
5 connected to the first electrode, and a second electrode surrounding the organic layer and electrically connected to the organic layer. In some embodiments, a pixel comprises a plurality of photovoltaic cells. In other embodiments, an optoelectronic device comprises an array of pixels. In a further embodiment, an optoelectronic device comprises an array of pixels, each pixel comprising a plurality of photovoltaic cells.

10 A method for producing an optoelectronic device, according to an embodiment of the present invention, comprises providing a fiber core, disposing a radiation transmissive first electrode on a surface of the core, disposing at least one photosensitive organic layer in electrical communication with the first electrode, and disposing a second electrode in electrical communication with the organic layer. In some embodiments, the optoelectronic
15 device comprises a photovoltaic cell.

The present invention additionally provides methods for converting electromagnetic energy into electrical energy. In an embodiment, a method of the present invention utilizes wave-guiding to increase the efficiency of conversion. Embodiments of optoelectronic devices of the present invention described herein may utilize wave-guiding to increase their
20 efficiency.

In one embodiment, a method for converting electromagnetic energy into electrical energy comprises receiving radiation along the longitudinal axis of an optical fiber, transmitting the radiation into at least one photosensitive organic layer through a radiation transmissive electrode surrounding the optical fiber, generating excitons in the organic layer,
25 and separating the excitons into electrons and holes. A method for converting electromagnetic energy into electrical energy, in some embodiments, further comprises removing the electrons into an external circuit.

In another embodiment, a method for converting electromagnetic energy into electrical energy comprises receiving radiation along the longitudinal axis of an optical fiber at an incident angle sufficient to produce total internal reflection at an interface of a
30 photosensitive organic layer and an adjacent layer disposed on a surface of the optical fiber.

These and other embodiments of the present invention are described in greater detail in the detailed description of the invention which follows.

Brief Description of the Figures

Figure 1 illustrates cut away view of an optoelectronic device comprising a fiber structure according to an embodiment of the present invention.

5 Figure 2 illustrates an cross sectional view of an optoelectronic device comprising a fiber structure according to an embodiment of the present invention.

Figure 3 illustrates an cross sectional view of an optoelectronic device comprising a fiber structure according to an embodiment of the present invention.

Figure 4 illustrates an optoelectronic device comprising a fiber structure according to an embodiment of the present invention.

10 Figure 5 illustrates a bundle of fiber photovoltaic cells according to an embodiment of the present invention.

Figure 6 displays current-voltage plots for a fiber photovoltaic device according to an embodiment of the present invention.

15 Figure 7 displays open circuit voltages for a fiber photovoltaic device according to an embodiment of the present invention.

Figure 8 displays short circuit currents for a fiber photovoltaic device according to an embodiment of the present invention.

Figure 9 displays conversion efficiencies for a fiber photovoltaic device according to an embodiment of the present invention.

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Detailed Description

The present invention provides organic optoelectronic devices, including organic photovoltaic devices, having a fiber structure. In one embodiment, the present invention provides an organic optoelectronic device comprising a fiber core, a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer
25 surrounding the first electrode and electrically connected to the first electrode, and a second electrode surrounding the organic layer and electrically connected to the organic layer. In some embodiments, the organic optoelectronic device comprises a photovoltaic cell.

Turning now to components that can be included in various embodiments of optoelectronic devices of the present invention, optoelectronic devices of the present
30 invention comprise a fiber core. The fiber core, according to embodiments of the present invention, comprises an optical fiber. Optical fibers suitable for use in the present invention can comprise glass optical fibers, quartz optical fibers, and plastic optical fibers (POF). Plastic optical fibers, in some embodiments, can be constructed of polymethyl methacrylate. In other embodiments, plastic optical fibers can be constructed of perfluorocyclobutane

(PFBC) containing polymers, such as perfluorocyclobutane poly(arylether)s. Optical fibers, according to some embodiments of the present invention, can comprise single mode optical fibers and multi-mode optical fibers. Optical fibers for use in the present invention can be flexible.

5 In some embodiments, a fiber core of an optoelectronic device of the present invention can have a diameter ranging from about 1 μm to about 2 mm. In other embodiments, a fiber core can have a diameter ranging from about 90 μm to about 1 mm. In a further embodiment, a fiber core can have a diameter ranging from about 20 μm to about 800 μm .

10 A fiber core, according to some embodiments, can have a length ranging from about 500 nm to about 100 mm. In other embodiments, a fiber core can have a length ranging from about 1 μm to about 1 mm. In a further embodiment, a fiber core can have a length ranging from about 10 μm to about 100 μm .

Fiber cores, according to some embodiments of the present invention, can further
15 comprise one or more upconverters. As understood by one of skill in the art, an upconverter is a material operable to emit electromagnetic radiation having energy greater than that of the electromagnetic radiation absorbed by the material to create the excited state. Upconverters suitable for use in the present invention, in some embodiments, can absorb infrared radiation and emit visible radiation at wavelengths operable to be absorbed by photosensitive organic
20 layers of optoelectronic devices of the present invention.

Upconverters, in some embodiments, can include materials comprising at least one Lanthanide series element. In some embodiments, upconverter materials can comprise nanoparticles comprising at least one Lanthanide series element. Lanthanide series elements suitable for use in upconverter materials according to some embodiments of the present
25 invention comprise erbium, ytterbium, dysprosium, holmium, or mixtures thereof. In some embodiments, upconverter materials comprise metal oxides and metal sulfides doped with ions of erbium, ytterbium, dysprosium, holmium, or mixtures thereof. In other embodiments, optical fibers may be doped directly with ions of erbium, ytterbium, dysprosium, holmium, or mixtures thereof.

30 In other embodiments, upconverter materials can comprise organic chemical species. Organic upconverter materials can comprise $\text{H}_2\text{C}_6\text{N}$ and 4-dialkylamino-1,8-naphthalimides as well as 1,8-naphthalimide derivatives and compounds, such as multibranched naphthalimide derivatives TPA-NA1, TPA-NA2, and TPA-NA3. Organic upconverter

materials can also comprise 4-(dimethylamino)cinnamotrile (*cis* and *trans*), *trans*-4-[4-(dimethylamino)styryl]-1-methylpyridinium iodide, 4-[4-(dimethylamino)styryl]pyridine, 4-(diethylamino)benzaldehyde diphenylhydrazone, *trans*-4-[4-(dimethylamino)styryl]-1-methylpyridinium *p*-toluenesulfonate, 2-[ethyl[4-[2-(4-nitrophenyl)ethenyl]phenyl]amino]ethanol, 4-dimethylamino-4'-nitrostilbene, Disperse Orange 25, Disperse Orange 3, and Disperse Red 1.

In a further embodiment, upconverter materials can comprise quantum dots. Quantum dots, according to some embodiments, can comprise III/V and II/VI semiconductor materials, such as cadmium selenide (CdSe), cadmium telluride (CdTe), and zinc selenide (ZnSe). Upconverter materials can also comprise core-shell architectures of quantum dots.

In addition to those provided herein, embodiments of the present invention contemplate additional upconverter materials comprising transition metals, such as chromium.

Upconverters, in some embodiments, can be disposed within the optical fiber core. In other embodiments, upconverters can be disposed on a surface of the optical fiber core and at the interface of the fiber core with a radiation transmissive first electrode.

Fiber cores, in some embodiments, can further comprise at least one scattering agent. In another embodiment, a fiber core can comprise a plurality of scattering agents. Scattering agents, according to embodiments of the present invention, can scatter electromagnetic radiation propagating along the longitudinal axis of the fiber core. In some embodiments, scattering agents can scatter the electromagnetic radiation radially outward from the fiber core permitting absorption of the scattered radiation by one or more photosensitive organic layers surrounding the fiber core.

Scattering agents, in some embodiments, can comprise transition metal nanoparticles. Transition metals suitable for use as scattering agents, in an embodiment, can comprise gold, silver, copper, niobium, palladium, and platinum. Transition metal nanoparticles, according to some embodiments, can comprise rods or wires. In one embodiment, for example, a transition metal nanorod or nanowire can have a diameter ranging from about 2 nm to about 50 nm.

Optoelectronic devices of the present invention comprise a radiation transmissive first electrode surrounding the fiber core. Radiation transmissive, as used herein, refers to the ability to at least partially pass radiation in the visible region of the electromagnetic spectrum. In some embodiments, radiation transmissive materials can pass visible electromagnetic radiation with minimal absorbance or other interference. Moreover, electrodes, as used

herein, refer to layers that provide a medium for delivering photo-generated current to an external circuit or providing bias voltage to the optoelectronic device. An electrode provides the interface between the photoactive regions of an organic optoelectronic device and a wire, lead, trace, or other means for transporting the charge carriers to or from the external circuit.

5 A radiation transmissive first electrode, according to some embodiments of the present invention, comprises a radiation transmissive conducting oxide. Radiation transmissive conducting oxides, in some embodiments, can comprise indium tin oxide (ITO), gallium indium tin oxide (GITO), and zinc indium tin oxide (ZITO). In another embodiment, the radiation transmissive first electrode can comprise a radiation transmissive polymeric
10 material such as polyaniline (PANI) and its chemical relatives. In some embodiments, 3,4-polyethylenedioxythiophene (PEDOT) can be a suitable radiation transmissive polymeric material for the first electrode. In other embodiments, a radiation transmissive first electrode can comprise a carbon nanotube layer having a thickness operable to at least partially pass visible electromagnetic radiation.

15 In another embodiment, a radiation transmissive first electrode can comprise a composite material comprising a nanoparticle phase dispersed in a polymeric phase. The nanoparticle phase, in one embodiment, can comprise carbon nanotubes, fullerenes, or mixtures thereof. In a further embodiment, a radiation transmissive first electrode can comprise a metal layer having a thickness operable to at least partially pass visible
20 electromagnetic radiation. In some embodiments, a metal layer can comprise elementally pure metals or alloys. Metals suitable for use as a radiation transmissive first electrode can comprise high work function metals.

In some embodiments, a radiation transmissive first electrode can have a thickness ranging from about 10 nm to about 1 μm . In other embodiments, a radiation transmissive
25 first electrode can have a thickness ranging from about 100 nm to about 900 nm. In another embodiment, a radiation transmissive first electrode can have a thickness ranging from about 200 nm to about 800 nm. In a further embodiment, a radiation transmissive first electrode can have a thickness greater than 1 μm .

30 Optoelectronic devices of the present invention comprise at least one photosensitive organic layer. Optoelectronic devices, according to some embodiments, can comprise a plurality of photosensitive organic layers.

In some embodiments, a photosensitive organic layer has a thickness ranging from about 30 nm to about 1 μm . In other embodiments, a photosensitive organic layer has a

thickness ranging from about 80 nm to about 800 nm. In a further embodiment, a photosensitive organic layer has a thickness ranging from about 100 nm to about 300 nm.

A photosensitive organic layer, according to embodiments of the present invention, comprises at least one photoactive region in which electromagnetic radiation is absorbed to produce excitons which may subsequently dissociate into electrons and holes. In some
5 embodiments, a photoactive region can comprise a polymer. Polymers suitable for use in a photoactive region of a photosensitive organic layer, in one embodiment, can comprise conjugated polymers such as thiophenes including poly(3-hexylthiophene) (P3HT), poly(3-octylthiophene) (P3OT), and polythiophene (PTh).

10 In some embodiments, polymers suitable for use in a photoactive region of a photosensitive organic layer can comprise semiconducting polymers. In one embodiment, semiconducting polymers include phenylene vinylenes, such as poly(phenylene vinylene) and poly(*p*-phenylene vinylene) (PPV), and derivatives thereof. In other embodiments, semiconducting polymers can comprise poly fluorenes, naphthalenes, and derivatives thereof.
15 In a further embodiment, semiconducting polymers for use in a photoactive region of a photosensitive organic layer can comprise poly(2-vinylpyridine) (P2VP), polyamides, poly(N-vinylcarbazole) (PVCZ), polypyrrole (PPy), and polyaniline (PAn).

A photoactive region, according to some embodiments, can comprise small molecules. In one embodiment, small molecules suitable for use in a photoactive region of a
20 photosensitive organic layer can comprise coumarin 6, coumarin 30, coumarin 102, coumarin 110, coumarin 153, and coumarin 480 D. In another embodiment, a small molecule can comprise merocyanine 540. In a further embodiment, small molecules can comprise 9,10-dihydrobenzo[*a*]pyrene-7(8*H*)-one, 7-methylbenzo[*a*]pyrene, pyrene, benzo[*e*]pyrene, 3,4-dihydroxy-3-cyclobutene-1,2-dione, and 1,3-bis[4-(dimethylamino)phenyl]-2,4-
25 dihydroxycyclobutenediylium dihydroxide.

In some embodiments of the present invention, exciton dissociation is precipitated at heterojunctions in the organic layer formed between adjacent donor and acceptor materials. Organic layers, in some embodiments of the present invention, comprise at least one bulk heterojunction formed between donor and acceptor materials. In other embodiments, organic
30 layers comprise a plurality of bulk heterojunctions formed between donor and acceptor materials.

In the context of organic materials, the terms donor and acceptor refer to the relative positions of the highest occupied molecular orbital (HOMO) and lowest unoccupied molecular orbital (LUMO) energy levels of two contacting but different organic materials.

This is in contrast to the use of these terms in the inorganic context, where donor and acceptor may refer to types of dopants that may be used to create inorganic n- and p-type layers, respectively. In the organic context, if the LUMO energy level of one material in contact with another is lower, then that material is an acceptor. Otherwise it is a donor. It is energetically favorable, in the absence of an external bias, for electrons at a donor-acceptor junction to move into the acceptor material, and for holes to move into the donor material.

A photoactive region in a photosensitive organic layer, according to some embodiments of the present invention, comprises a polymeric composite material. The polymeric composite material, in an embodiment, can comprise a nanoparticle phase dispersed in a polymeric phase. Polymers suitable for producing the polymeric phase of a photoactive region can comprise conjugated polymers such as thiophenes including poly(3-hexylthiophene) (P3HT) and poly(3-octylthiophene) (P3OT).

In some embodiments, the nanoparticle phase dispersed in the polymeric phase of a polymeric composite material comprises at least one carbon nanoparticle. Carbon nanoparticles can comprise fullerenes, carbon nanotubes, or mixtures thereof. Fullerenes suitable for use in the nanoparticle phase, in one embodiment, can comprise 1-(3-methoxycarbonyl)propyl-1-phenyl(6,6) C_{60} (PCBM). Carbon nanotubes for use in the nanoparticle phase, according to some embodiments, can comprise single-walled nanotubes, multi-walled nanotubes, or mixtures thereof.

In some embodiments of the present invention, the polymer to nanoparticle ratio in polymeric composite materials ranges from about 1:4 to about 1:0.4. In other embodiments, the polymer to nanoparticle ratio in polymeric composite materials ranges from about 1:2 to about 1:0.6. In one embodiment, for example, the ratio of poly(3-hexylthiophene) to PCBM ranges from about 1:1 to about 1:0.4.

In a further embodiment, the nanoparticle phase dispersed in the polymeric phase comprises at least one nanowhisker. A nanowhisker, as used herein, refers to a crystalline carbon nanoparticle formed from a plurality of carbon nanoparticles. Nanowhiskers, in some embodiments, can be produced by annealing a photosensitive organic layer comprising the polymeric composite material. Carbon nanoparticles operable to form nanowhiskers, according to some embodiments, can comprise single-walled carbon nanotubes, multi-walled carbon nanotubes, and fullerenes. In one embodiment, nanowhiskers comprise crystalline PCBM. Annealing the photosensitive organic layer, in some embodiments, can further increase the dispersion of the nanoparticle phase in the polymeric phase.

In embodiments of photoactive regions comprising a polymeric phase and a nanoparticle phase, the polymeric phase serves as a donor material and the nanoparticle phase serves as the acceptor material thereby forming a heterojunction for the separation of excitons into holes and electrons. In embodiments wherein nanoparticles are dispersed throughout the polymeric phase, the photoactive region of the organic layer comprises a plurality of bulk heterojunctions.

In further embodiments, donor materials in a photoactive region of a photosensitive organic layer can comprise organometallic compounds including porphyrins, phthalocyanines, and derivatives thereof. Through the use of an organometallic material in the photoactive region, photosensitive devices incorporating such materials may efficiently utilize triplet excitons. It is believed that the singlet-triplet mixing may be so strong for organometallic compounds that the absorptions involve excitation from the singlet ground states directly to the triplet excited states, eliminating the losses associated with conversion from the singlet excited state to the triplet excited state. The longer lifetime and diffusion length of triplet excitons in comparison to singlet excitons may allow for the use of a thicker photoactive region, as the triplet excitons may diffuse a greater distance to reach the donor-acceptor heterojunction, without sacrificing device efficiency.

In further embodiments, acceptor materials in a photoactive region of a photosensitive organic layer can comprise perylenes, naphthalenes, and mixtures thereof.

Optoelectronic devices of the present invention comprise a second electrode surrounding the organic layer. In some embodiments, the second electrode can comprise a metal. As used herein, metal refers to both materials composed of an elementally pure metal, e.g., gold, and also metal alloys comprising materials composed of two or more elementally pure materials. In some embodiments, the second electrode comprises gold, silver, aluminum, or copper. The second electrode, according to some embodiments, can have a thickness ranging from about 10 nm to about 10 μ m. In other embodiments, the second electrode can have a thickness ranging from about 100 nm to about 1 μ m. In a further embodiment, the second electrode can have a thickness ranging from about 200 nm to about 800 nm.

A layer comprising lithium fluoride (LiF), according to some embodiments, can be disposed between a photosensitive organic layer and second electrode. The LiF layer can have a thickness ranging from about 5 angstroms to about 10 angstroms.

Optoelectronic devices of the present invention, in some embodiments, can further comprise additional layers such as one or more exciton blocking layers. In embodiments of the present invention, an exciton blocking layer (EBL) can act to confine photogenerated excitons to the region near the dissociating interface and prevent parasitic exciton quenching at a photosensitive organic/electrode interface. In addition to limiting the path over which excitons may diffuse, an EBL can additionally act as a diffusion barrier to substances introduced during deposition of the electrodes. In some embodiments, an EBL can have a sufficient thickness to fill pin holes or shorting defects which could otherwise render an organic photovoltaic device inoperable.

10 An EBL, according to some embodiments of the present invention, can comprise a polymeric composite material. In one embodiment, an EBL comprises carbon nanoparticles dispersed in 3,4-polyethylenedioxythiophene:polystyrenesulfonate (PEDOT:PSS). In another embodiment, an EBL comprises carbon nanoparticles dispersed in poly(vinylidene chloride) and copolymers thereof. Carbon nanoparticles dispersed in the polymeric phases including PEDOT:PSS and poly(vinylidene chloride) can comprise single-walled nanotubes, multi-walled nanotubes, fullerenes, or mixtures thereof. In further embodiments, EBLs can comprise any polymer having a work function energy operable to permit the transport of holes while impeding the passage of electrons.

20 In some embodiments, an EBL may be disposed between the radiation transmissive first electrode and a photosensitive organic layer of an optoelectronic device. In some embodiments wherein the optoelectronic device comprises a plurality of photosensitive organic layers, EBLs can be disposed between the photosensitive organic layers.

Optoelectronic devices of the present invention, in some embodiments, can further comprise a protective layer surrounding the second electrode. The protective layer can provide optoelectronic devices provided herein with increased durability thereby permitting their use in a wide variety of applications including photovoltaic applications. In some embodiments, the protective layer comprises a polymeric composite material. In one embodiment, the protective layer comprises nanoparticles dispersed in poly(vinylidene chloride). Nanoparticles dispersed in poly(vinylidene chloride), according to some 25 30 embodiments, can comprise single-walled carbon nanotubes, multi-walled carbon nanotubes, fullerenes, or mixtures thereof.

Optoelectronic devices of the present invention, in some embodiments, can further comprise an external metallic contact. In one embodiment, the external metallic contact surrounds the second electrode and is in electrical communication with the second electrode.

The external metallic contact, in some embodiments, can be operable to extract current over at least a portion of the circumference and length of the fiber optoelectronic device. In other embodiments, the external metal contact can be operable to extract current over the entire length and circumference of the fiber optoelectronic device. External metallic contacts, in
5 some embodiments, can comprise metals including gold, silver, or copper. In a further embodiment, external metal contacts can be operable to reflect non-absorbed electromagnetic radiation back into at least one photosensitive organic layer for further absorption.

Optoelectronic devices, according to some embodiments of the present invention, can further comprise charge transfer layers. Charge transfer layers, as used herein, refer to layers
10 which only deliver charge carriers from one section of an optoelectronic device to another section. In one embodiment, for example, a charge transfer layer can comprise an exciton blocking layer.

A charge transfer layer, in some embodiments, can be disposed between a photosensitive organic layer and radiation transmissive first electrode and/or a photosensitive
15 organic layer and second electrode. In other embodiments, charge transfer layers may be disposed between the second electrode and protective layer of an optoelectronic device. Charge transfer layers, according to some embodiments, are not photoactive.

Figure 1 illustrates cut-away view of an optoelectronic device having a fiber structure according to one embodiment of the present invention. The optoelectronic device (100)
20 shown in Figure 1 comprises an optical fiber core (102). As discussed herein, the fiber core (102) can comprise a glass optical fiber, a quartz optical fiber, or a plastic optical fiber.

The optical fiber core (102) is longitudinally surrounded by a radiation transmissive first electrode (104). The radiation transmissive first electrode (104) can comprise a radiation transmissive conducting oxide such as indium tin oxide, gallium indium tin oxide, or zinc
25 indium tin oxide. The radiation transmissive first electrode (104) is surrounded by an exciton blocking layer (106). In some embodiments, the EBL (106) can comprise carbon nanoparticles dispersed in a polymeric phase such as 3,4-polyethylenedioxythiophene or poly(vinylidene chloride).

The EBL (106) is surrounded by an photosensitive organic layer (108). The
30 photosensitive organic layer (108), in some embodiments, comprises a P3HT-carbon nanoparticle polymeric composite. The photosensitive organic layer (108), in some embodiments, can be in direct electrical communication with the radiation transmissive first electrode (104). In other embodiments, a charge transfer layer, including an exciton blocking layer, may be disposed between the radiation transmissive first electrode (104) and the

photosensitive organic layer (108) to provide indirect electrical communication between the radiation transmissive first electrode (104) and the photosensitive organic layer (108).

The photosensitive organic layer (108) is surrounded by a second electrode (110). The photosensitive organic layer (108), in some embodiments, can be in direct electrical communication with the second electrode (110). In other embodiments, a charge transfer layer, such as an exciton blocking layer, (not shown) may be disposed between the photosensitive organic layer (108) and the second electrode (110) to provide indirect electrical communication between the photosensitive organic layer (108) and the second electrode (110). In some embodiments, the second electrode (110) comprises a metal, such as aluminum, gold, silver, nickel, or copper.

The second electrode (110) is surrounded by a protective layer (112) comprising a polymeric composite material. In some embodiments, the polymeric composite material of the protective layer comprises carbon nanoparticles dispersed in poly(vinylidene chloride) and/or copolymers thereof. The carbon nanoparticles can comprise single-walled carbon nanotubes, multi-walled carbon nanotubes, fullerenes, or mixtures thereof.

The protective layer (112) is surrounded by an external metal contact (114) operable to extract current over a length and circumference of the fiber optoelectronic device. In some embodiments, an external metallic (114) contact can comprise metals including gold, silver, or copper.

Figure 2 illustrates a cross-sectional view of an optoelectronic device comprising a fiber structure according to another embodiment of the present invention. The optoelectronic device (200) displayed in Figure 2 comprises an optical fiber core (202) and a radiation transmissive first electrode (204) surrounding the optical fiber core (202). An exciton blocking layer (206) surrounds the radiation transmissive first electrode (204), and a photosensitive organic layer (208) surrounds the exciton blocking layer (206). A second electrode (210) surrounds the photosensitive organic layer (208). The compositions of the optical fiber core (202) and surrounding layers (204-210) are consistent with those provided in the various embodiments described herein.

In the embodiment shown in Figure 2, the optical fiber core (202) and radiation transmissive first electrode (204) extend longitudinally beyond the remaining layers of the optoelectronic device (200). The longitudinal extension of the optical fiber core (202) and radiation transmissive first electrode (204), in some embodiments, can facilitate attachment of the optoelectronic device (200) to an external electrical circuit.

Figure 3 illustrates a cross-sectional view of an optoelectronic device comprising a fiber structure according to another embodiment of the present invention, wherein the optoelectronic device comprises a plurality of photosensitive organic layers. The optoelectronic device (300) comprises an optical fiber core (302). The fiber core (302) can
5 comprise a glass optical fiber, a quartz optical fiber, or a plastic optical fiber.

The optical fiber core (302) is surrounded by a radiation transmissive first electrode (304). The radiation transmissive first electrode (304) can comprise a radiation transmissive conducting oxide such as indium tin oxide, gallium indium tin oxide, or zinc indium tin oxide. The radiation transmissive first electrode is surrounded by a first exciton blocking
10 layer (306). In some embodiments, the first EBL (306) can comprise carbon nanoparticles dispersed in a polymeric phase such as 3,4-polyethylenedioxythiophene or poly(vinylidene chloride).

The first EBL (306) is surrounded by a first photosensitive organic layer (308). The first photosensitive organic layer (308), in some embodiments, can comprise a P3HT-carbon nanoparticle polymeric composite. The first photosensitive organic layer (308) is surrounded
15 by a second exciton blocking layer (310). The second EBL, in some embodiments, can also comprise carbon nanoparticles dispersed in 3,4-polyethylenedioxythiophene or poly(vinylidene chloride).

The second EBL is surrounded by a second photosensitive organic layer (312). The second photosensitive organic layer (312), in some embodiments, can comprise a polymeric material, including a polymeric composite, having an electromagnetic radiation absorption profile that largely overlaps that of the first organic layer (308). In other embodiments, the second photosensitive organic layer (312) can comprise a polymeric material, including a polymeric composite, having an electromagnetic radiation absorption profile that does not
20 overlap or minimally overlaps that of the first organic layer (308).

The second organic layer (312) is surrounded by a second electrode (314) that can reflect electromagnetic radiation not absorbed by the photosensitive organic layers (308), (312) back into the organic layers for absorption. The second electrode (314), in some
25 embodiments, comprises a metal, such as aluminum, gold, silver, nickel, or copper.

In the embodiment shown in Figure 3, the optical fiber core (302), radiation transmissive first electrode (304), and second exciton blocking layer (310) extend longitudinally beyond the remaining layers of the optoelectronic device. The longitudinal extension of the optical fiber core (302), radiation transmissive first electrode (304), and
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second exciton blocking layer (310) can facilitate attachment of the optoelectronic device (300) to an external electrical circuit.

Although Figure 3 illustrates an optoelectronic device having two photosensitive organic layers, embodiments of the present invention contemplate optoelectronic devices comprising greater than two photosensitive organic layers, including optoelectronic devices having three, four, five, and greater than five photosensitive organic layers. In some embodiments, an optoelectronic device can comprise at least 10 photosensitive organic layers.

A plurality of photosensitive organic layers can be buffered from one another, in some embodiments, by disposing exciton blocking layers between the photosensitive organic layers. By providing a plurality of photosensitive organic layers wherein each layer has a distinct absorption profile, optoelectronic devices of the present invention can increase or maximize exciton generation across the electromagnetic spectrum.

In some embodiments, an optoelectronic device can comprise a fiber core having a plurality of photosensitive regions located along its longitudinal axis, each of the plurality of photosensitive regions comprises a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode, and a second electrode surrounding the organic layer and electrically connected to the organic layer. Each of the plurality of regions may further comprise additional layers as set forth herein, including additional photosensitive organic and exciton blocking layers as provided in Figure 3.

Figure 4 illustrates an optoelectronic device (400) comprising a fiber core (402) having a plurality of photosensitive regions (404, 406, 408) disposed along its longitudinal axis. In some embodiments, the photosensitive organic layer or layers of each region (404, 406, 408) can be chosen to have a distinct electromagnetic radiation absorption profile that does not overlap or minimally overlaps with the absorption profiles of the other regions. In the present embodiment, for example, the photosensitive organic layer of region 404 can have an absorption profile ranging from about 400 nm to about 600 nm while the photosensitive organic layer of region 406 can have an absorption profile ranging from about 600 nm to about 800 nm. The photosensitive organic layer of region 408 can have an absorption profile ranging from about 800 nm to about 1100 nm.

By providing a plurality of photosensitive regions wherein each region comprises at least one photosensitive organic layer having a distinct absorption profile, optoelectronic

devices of the present invention can increase or maximize exciton generation across the electromagnetic spectrum.

5 In some embodiments, the fiber core of an optoelectronic device comprising a plurality of photosensitive regions can be partially coated with a non-radiation transmissive material that prevents electromagnetic radiation propagating along the longitudinal axis of the fiber from escaping the fiber. Suitable coating materials can comprise metal cladding or any other material that promotes internal reflection. As shown in Figure 4, the optical fiber core (402) can be coated with metal cladding (410) between the photosensitive regions (404, 406, 408). The optical fiber core is not coated with metal cladding or other non-radiation
10 transmissive material in the photosensitive regions.

In some embodiments, an optoelectronic device having a fiber structure comprises a photovoltaic cell. In one embodiment, a photovoltaic cell comprises a fiber core, a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode, and a
15 second electrode surrounding the organic layer and electrically connected to the organic layer. In another embodiment, the photovoltaic cell comprises a plurality of photosensitive organic layers as provided herein.

In a further embodiment, a photovoltaic cell comprises a fiber core comprising a plurality of photosensitive regions disposed along the longitudinal axis of the fiber core, each
20 photosensitive region comprising a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode, and a second electrode surrounding the organic layer and electrically connected to the organic layer.

Fiber photovoltaic cells, according to embodiments of the present invention, are
25 operable to receive electromagnetic radiation along the longitudinal axis of the optical fiber core. Electromagnetic radiation received along the longitudinal axis of the optical fiber core, in some embodiments, can be transmitted through the radiation transmissive first electrode and into the photosensitive organic layer through evanescent fields. In other embodiments, the received electromagnetic radiation can be scattered into the photosensitive organic layer
30 by scattering agents within the optical fiber. In a further embodiment, at least a portion of the received electromagnetic radiation can undergo upconversion and be emitted into the photosensitive organic layer.

Fiber photovoltaic devices, according to some embodiments of the present invention, can display a fill factor greater than 0.2. In other embodiments, fiber photovoltaic devices

can demonstrate a fill factor greater than 0.5. In a further embodiment, fiber photovoltaic devices can display a fill factor greater than 0.7.

In some embodiments, fiber photovoltaic devices of the present invention can display conversion efficiencies, η_p , greater than about 6%. Fiber photovoltaic devices, in other
5 embodiments, can demonstrate conversion efficiencies greater than about 10%. In another embodiment, fiber photovoltaic devices can display conversion efficiencies greater than about 15%. In a further embodiment, fiber photovoltaic devices can display conversion efficiencies greater than 35%.

In some embodiments, the present invention provides an optoelectronic device
10 comprising at least one pixel comprising at least one photovoltaic cell, the photovoltaic cell comprising a fiber core, a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode, and a second electrode surrounding the organic layer and electrically connected to the organic layer. In some embodiments, a photovoltaic cell of a
15 pixel comprises a plurality of photosensitive organic layers.

In a further embodiment, a photovoltaic cell of a pixel comprises a fiber core comprising a plurality of photosensitive regions disposed along the longitudinal axis of the fiber core, each photosensitive region comprising a radiation transmissive first electrode surrounding the fiber core, at least one photosensitive organic layer surrounding the first
20 electrode and electrically connected to the first electrode, and a second electrode surrounding the at least one organic layer and electrically connected to the organic layer.

In some embodiments, a pixel comprises a plurality of photovoltaic cells. In other embodiments, an optoelectronic device comprises an array of pixels. In a further embodiment, an optoelectronic device comprises an array of pixels, each pixel comprising a
25 plurality of photovoltaic cells.

Fiber photovoltaic cells for use in pixel applications, in some embodiments of the present invention, are constructed independently from one another. In such embodiments, component materials for one fiber photovoltaic cell are selected without reference to component materials selected for another fiber photovoltaic cell. In one embodiment, for
30 example, one fiber photovoltaic cell can comprise a glass optical fiber core while another photovoltaic cell can comprise a plastic optical fiber core. As a result, in some embodiments, pixels and pixel arrays are not required to comprise fiber photovoltaic cells of identical construction. Fiber photovoltaic cell construction can be varied in any manner consistent

with the materials and methods described herein to produce pixels and pixel arrays suitable for a wide range of applications.

In some embodiments, a plurality of fiber photovoltaic cells can be bundled. In such embodiments, each fiber photovoltaic cell can constitute a single pixel or the plurality of fiber photovoltaic cells can collectively constitute a single pixel.

Figure 5 illustrates a bundle (500) of fiber photovoltaic cells (502) according to an embodiment of the present invention. The fiber photovoltaic cells (502) can be disposed on a connection plate (504) for incorporation into an external electrical circuit (506). Each fiber photovoltaic cell (502) is disposed on the connection plate (504) through a longitudinal extension (508) of the optical fiber core.

As illustrated in Figures 2 and 3, the longitudinal extension (508) of a fiber photovoltaic cell (502) can comprise the optical fiber core, the radiation transmissive first electrode, and any exciton blocking layers operable to transport desired excitons generated in photosensitive organic layers to the radiation transmissive first electrode. Connection to the external circuit (506) can be completed through the external metallic contacts (510) of the fiber photovoltaic cells (502).

In some embodiments, a photosensitive material can be used as a matrix in which to bundle a plurality of fiber photovoltaic cells. Photosensitive materials for bundling fiber photovoltaic cells can comprise polymeric materials. Polymeric materials suitable for use as a bundling matrix, in some embodiments, can comprise conjugated polymers such as thiophenes including poly(3-hexylthiophene) (P3HT) and poly(3-octylthiophene) (P3OT). In other embodiments, polymeric materials suitable for use as a bundling matrix can comprise semiconducting polymers as provided hereinabove, including PPV, PPy, and PAn.

In Figure 5, for example, a photosensitive polymer, such as poly(3-hexylthiophene), can be disposed on the connection plate (504) and in the spaces between the fiber photovoltaic cells (502). The poly(3-hexylthiophene) can be in contact with the longitudinal extension (508) of the optical fiber core and the external metal contact (510) of each fiber photovoltaic cell (502). When exposed to electromagnetic radiation, the poly(3-hexylthiophene) matrix can generate excitons in addition to those generated by the fiber photovoltaic cells (502). The poly(3-hexylthiophene) matrix can transfer the additional excitons to the fiber photovoltaic cells (502) through the longitudinal extensions (508) of the optical fiber cores and the external metal contacts (510). Fiber photovoltaic cells (502) receiving excitons generated by the poly(3-hexylthiophene) matrix can subsequently transport the excitons into the external electrical circuit (506).

Optoelectronic devices comprising at least one pixel comprising at least one fiber photovoltaic cell, in some embodiments, comprise solar cells. Pixels and pixel arrays can be placed on any suitable substrate, in some embodiments, to produce solar panels. Solar cells and panels comprising fiber photovoltaic cells of the present invention can have conversion efficiencies greater than 6%.

The present invention also provides methods for producing optoelectronic devices comprising providing a fiber core, disposing a radiation transmissive first electrode on a surface of the fiber core, disposing at least one photosensitive organic layer in electrical communication with the first electrode, and disposing a second electrode in electrical communication with the organic layer. Materials suitable for the fiber core, radiation transmissive first electrode, photosensitive organic layer or layers, second electrode, protective layer, and external metallic contact, in embodiments of methods of the present invention, are consistent with those provided for optoelectronic devices having a fiber structure described herein.

Disposing a radiation transmissive first electrode on a fiber core, in some embodiments, comprises sputtering or dip coating a radiation transmissive conductive oxide onto a surface of the fiber core. In some embodiments, disposing a photosensitive organic layer in electrical communication with the first electrode comprises depositing the organic layer on the first electrode by dip coating, spin coating, vapor phase deposition, or vacuum thermal annealing. Disposing a second electrode in electrical communication with the photosensitive organic layer, according to some embodiments, comprises depositing the second electrode on the organic layer through vapor phase deposition, spin coating, or dip coating.

Methods of producing an optoelectronic device, in some embodiments, further comprises annealing the photosensitive organic layer or layers. In some embodiments where a photosensitive organic layer comprises a composite material comprising a polymer phase and a nanoparticle phase, annealing the organic layer can produce higher degrees of crystallinity in both the polymer and nanoparticle phases as well as result in greater dispersion of the nanoparticle phase in the polymer phase. Nanoparticle phases comprising fullerenes, single-walled carbon nanotubes, multi-walled carbon nanotubes, or mixtures thereof can form nanowhiskers in the polymeric phase as a result of annealing. Annealing a photosensitive organic layer, according to some embodiments, can comprise heating the organic layer at a temperature ranging from about 80°C to about 155°C for a time period of

ranging from about 1 minute to about 30 minutes. In some embodiments, a photosensitive organic layer can be heated for about 5 minutes.

In some embodiments, a method for producing an optoelectronic device further comprises disposing at least one upconverter and/or scattering agent in the fiber core.

5 In addition to methods of producing optoelectronic devices, the present invention also provides methods for converting electromagnetic energy into electrical energy. Wave-guiding may be utilized to increase the efficiency of the conversion.

In an embodiment, the present invention provides a method for converting electromagnetic energy in the form of waves into electrical energy, the method comprising:
10 receiving an electromagnetic wave; and guiding the electromagnetic wave to transmit radiation into a photosensitive layer. In some embodiments, guiding the electromagnetic wave to transmit radiation into a photosensitive organic layer can comprise creating total internal reflection of the electromagnetic wave at an interface of a photosensitive organic layer and an adjacent layer to produce evanescent waves or fields in the photosensitive
15 organic layer.

In an embodiment, a method for converting electromagnetic energy into electrical energy comprises receiving radiation along the longitudinal axis of an optical fiber, transmitting the radiation into at least one photosensitive organic layer through a radiation transmissive electrode surrounding the optical fiber, generating excitons in the photosensitive
20 organic layer, and separating the excitons into electrons and holes at a heterojunction in the organic layer.

In some embodiments, a heterojunction comprises a plurality of bulk heterojunctions. As discussed herein, a bulk heterojunction is formed at the interface of a donor material and an acceptor material. In some embodiments, a donor material comprises a polymeric phase
25 and the acceptor material comprises a nanoparticle phase. Donor and acceptor materials for use in methods of the present invention are consistent with those provided herein for optoelectronic devices.

Electromagnetic radiation received along the longitudinal axis of an optical fiber, in some embodiments, comprises visible radiation. In other embodiments, radiation received
30 along the longitudinal axis of an optical fiber comprises infrared radiation.

In some embodiments, transmitting electromagnetic radiation into a photosensitive organic layer comprises transmitting radiation through evanescence fields. In other
embodiments, transmitting electromagnetic radiation into a photosensitive organic layer comprises upconverting at least a portion of the electromagnetic radiation received along the

longitudinal axis of the optical fiber. Upconverting, according to embodiments of the present invention, comprises absorbing radiation received along the longitudinal axis of an optical fiber with an upconversion material to create an excited state and emitting radiation into at least one organic layer to relax the excited state, wherein the emitted radiation has a shorter wavelength than the absorbed radiation. In some embodiments, the portion of radiation absorbed by the upconversion material comprises infrared radiation.

In a further embodiment, transmitting the radiation received along the longitudinal axis of an optical fiber into a photosensitive organic layer comprises scattering the radiation into the organic layer with a scattering agent.

A method for converting electromagnetic energy into electrical energy, according to embodiments of the present invention, can further comprise removing the electrons into an external circuit.

The present invention will now be illustrated by the following non-limiting example.

EXAMPLE 1

Fiber Photovoltaic Cell

A non-limiting example of a fiber photovoltaic cell was prepared according to the following procedure.

The jacket of a multi-mode fiber (BFH37, High OH, from 1.5 mm to 0.6mm, from Thorlabs) was stripped off with a razor. The hard polymer cladding was burned away with a torch flame. The core of the fiber was then cleaned in an ultrasonic bath with deionized water, acetone, isopropyl alcohol successively for 20 min, and dried in oven for 15 min at 100°C. The cleaned fiber was subsequently coated with indium-tin-oxide (In/Sn=90:10) by dip coating (over 10 layers). See Dip Coated ITO thin films through sol-gel process using metal salts, Sutapa Roy Ramanan, *Thin Solid Films*, 389 (2001), 207.

The ITO coated fiber was thoroughly cleaned in an ultrasonic bath with acetone and isopropyl alcohol successively for 20 min, and dried in oven at 100°C. The fiber was then exposed to ozone for 90 min (rotating the fiber 3 times every after 30 min). A PEDOT:PSS solution (Baytron P from Bayer) was subsequently deposited on the fiber by dip coating and dried at 100°C for 15 min. (the thickness of PEDOT:PSS film was about 150 nm).

Subsequently, a solution of P3HT (American Dye):PCBM (American Dye)=1:0.8 in chlorobenzene was deposited on the fiber through dip coating. (the thickness of polymer film was about 300 nm). In the final steps, LiF and Al electrodes were deposited via thermal evaporation at the pressure of 10^{-6} torr. The thickness of LiF was about 0.3-0.4 nm, and the

thickness of Al film was about 100 nm. The length of the fiber with active area is about 1.4 cm.

After preparation, the fiber photovoltaic cell was characterized in terms of current density, open circuit voltage, short circuit current, and efficiency. Figure 6 displays current-voltage plots for the fiber photovoltaic cell in relation to radiation coupling angle. Figure 6(a) displays a current-voltage plot for the fiber photovoltaic cell prior to annealing the photosensitive organic layer, and Figure 6(b) displays a current-voltage plot for the fiber photovoltaic cell subsequent to annealing the photosensitive organic layer.

Figure 7 demonstrates open circuit voltage (V_{oc}) versus radiation coupling angle for the fiber photovoltaic cell prior to annealing the photosensitive organic layer and subsequent to annealing the photosensitive organic layer. As displayed in the plot, annealing the photosensitive organic layer increases the open circuit voltage of the fiber photovoltaic cell.

Figure 8 displays short circuit current (I_{sc}) versus radiation coupling angle for the fiber photovoltaic cell prior to annealing the photosensitive organic layer and subsequent to annealing the photosensitive organic layer. As with the open circuit voltage, the short circuit current of the fiber photovoltaic cell increases after annealing the photosensitive organic layer.

Figure 9 displays conversion efficiency versus radiation coupling angle for the fiber photovoltaic cell prior to annealing the photosensitive organic layer and subsequent to annealing the photosensitive organic layer. Consistent with the pattern displayed by in the previous figures, Figure 5 demonstrates an increased conversion efficiency for the fiber photovoltaic subsequent to annealing.

Various embodiments of the invention have been described in fulfillment of the various objects of the invention. It should be recognized that these embodiments are merely illustrative of the principles of the present invention. Numerous modifications and adaptations thereof will be readily apparent to those skilled in the art without departing from the spirit and scope of the invention.

That which is claimed is:

1. An apparatus comprising:
a fiber core;
a radiation transmissive first electrode surrounding the fiber core;
at least one photosensitive organic layer surrounding the first electrode and
5 electrically connected to the first electrode; and
a second electrode surrounding the organic layer and electrically connected to the organic layer.
2. The apparatus of claim 1, wherein the fiber core comprises an optical fiber.
3. The apparatus of claim 2, wherein the optical fiber comprises a glass optical fiber,
10 quartz optical fiber, or a plastic optical fiber.
4. The apparatus of claim 1, wherein the radiation transmissive first electrode comprises a radiation transmissive conducting oxide.
5. The apparatus of claim 4, wherein the radiation transmissive conducting oxide comprises indium tin oxide, gallium indium tin oxide, or zinc indium tin oxide.
- 15 6. The apparatus of claim 1, wherein the photosensitive organic layer comprises a photoactive region.
7. The apparatus of claim 6, wherein the photoactive region comprises at least one bulk heterojunction between a donor material and an acceptor material.
8. The apparatus of claim 7, wherein the donor material comprises a polymeric phase
20 and the acceptor material comprises nanoparticle phase.
9. The apparatus of claim 8, wherein the polymeric phase comprises a conjugated polymer.
10. The apparatus of claim 9, wherein the conjugated polymer comprises poly(3-hexylthiophene), poly(3-octylthiophene), or mixtures thereof.
- 25 11. The apparatus of claim 8 wherein the nanoparticle phase comprises fullerenes, carbon nanotubes, or mixtures thereof.
12. The apparatus of claim 11, wherein the fullerenes comprise 1-(3-methoxycarbonyl)propyl-1-phenyl(6,6)C₆₁.
13. The apparatus of claim 7, wherein the donor material comprises organometallic
30 compounds.
14. The apparatus of claim 13, wherein the organometallic compounds comprise phthalocyanines, porphyrins, or derivatives thereof.

15. The apparatus of claim 7, wherein the acceptor material comprises perylenes, naphthalenes, fullerenes, or nanotubes.
16. The apparatus of claim 1, wherein the second electrode comprises a metal.
17. The apparatus of claim 16, wherein the metal comprises aluminum, gold, silver, or copper.
18. The apparatus of claim 1 further comprising at least one blocking layer.
19. The apparatus of claim 18, wherein the at least one blocking layer comprises a polymeric composite.
20. The apparatus of claim 19, wherein the polymeric composite comprises a plurality of nanotubes or fullerenes dispersed in poly(3,4-ethylenedioxythiophene).
21. The apparatus of claim 19, wherein the polymeric composite comprises a plurality of nanotubes or fullerenes dispersed in poly(vinylidene fluoride).
22. The apparatus of claim 1 further comprising a protective layer surrounding the second electrode.
23. The apparatus of claim 22, wherein the protective layer comprises a polymeric composite material.
24. The apparatus of claim 23, wherein the polymeric composite material comprises carbon nanoparticles dispersed in poly(vinylidene chloride).
25. The apparatus of claim 2, wherein the optical fiber core comprises at least one upconversion material.
26. The apparatus of claim 25, wherein the at least one upconversion material comprises a Lanthanide series element.
27. The apparatus of claim 26, wherein the at least one upconversion material comprises erbium, ytterbium, dysprosium, holmium, or mixtures thereof.
28. The apparatus of claim 25, wherein the at least one upconversion material comprises at least one nanoparticle comprising at least one Lanthanide series element.
29. The apparatus of claim 2, wherein the optical fiber core comprises at least one scattering agent.
30. The apparatus of claim 1, wherein the fiber core has a diameter ranging from about 100 μm to about 2 mm.
31. The apparatus of claim 1, wherein the fiber core has a length ranging from about 10 μm to about 1 mm.

32. The apparatus of claim 1, wherein the radiation transmissive first electrode has a thickness ranging from about 100 nm to about 1 μ m.
33. The apparatus of claim 1, wherein the organic layer has a thickness ranging from about 30 nm to about 1 μ m.
- 5 34. The apparatus of claim 1, wherein the second electrode has a thickness of at least 5 nm.
35. The apparatus of claim 1, wherein the apparatus is flexible.
36. The apparatus of claim 1, wherein the apparatus is a photovoltaic cell.
37. A method of producing a photovoltaic cell comprising:
- 10 providing a fiber core;
disposing a radiation transmissive first electrode on a surface of the core;
disposing at least one photosensitive organic layer in electrical communication with the first electrode; and
disposing a second electrode in electrical communication with the organic layer.
- 15 38. The method of claim 37, wherein the fiber core comprises an optical fiber.
39. The method of claim 37, wherein the radiation transmissive first electrode comprises a radiation transmissive conducting oxide.
40. The method of claim 39, wherein the radiation transmissive conducting oxide comprises indium tin oxide, gallium indium tin oxide, or zinc indium tin oxide.
- 20 41. The method of claim 37, wherein the photosensitive organic layer comprises a photoactive region.
42. The method of claim 41, wherein the photoactive region comprises at least one bulk heterojunction between a donor material and an acceptor material.
43. The method of claim 42, wherein the donor material comprises a polymeric phase and
25 the acceptor material comprises a nanoparticle phase.
44. The method of claim 43, wherein the donor material comprises an organometallic compound and the acceptor material comprises perylenes, naphthalenes, fullerenes, or nanotubes.
45. The method of claim 37 further comprising annealing the photosensitive organic layer
30 to produce nanowhiskers in the organic layer.
46. The method of claim 45, wherein the nanowhiskers comprise crystalline 1-(3-methoxycarbonyl)propyl-1-phenyl(6,6) C_{60} .

47. The method of claim 37, wherein disposing a radiation transmissive first electrode comprises sputtering or dip coating a radiation transmissive conductive oxide onto the surface of the core.

48. The method of claim 37, wherein disposing an organic layer in electrical communication with the first electrode comprises depositing the organic layer on the first electrode by dip coating, spin coating, vapor phase deposition, or vacuum thermal evaporation.

49. The method of claim 37, wherein disposing a second electrode in electrical communication with the organic layer comprises depositing the second electrode on the organic layer through vapor phase deposition, spin coating, or dip coating.

50. The method of claim 37 further comprising providing at least one upconverter in the optical fiber.

51. The method of claim 37 further comprising providing at least one scattering agent in the optical fiber.

52. A photoactive apparatus comprising:

at least one pixel comprising at least one photovoltaic cell, the photovoltaic cell comprising:

a fiber core;

a radiation transmissive first electrode surrounding the fiber core;

at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode; and

a second electrode surrounding the organic layer and electrically connected to the organic layer.

53. The apparatus of claim 52, wherein the fiber core comprises an optical fiber.

54. The apparatus of claim 53, wherein the optical fiber comprises a glass optical fiber, quartz optical fiber, or a plastic optical fiber.

55. The apparatus of claim 52, wherein the at least one pixel comprises a plurality of photovoltaic cells.

56. The apparatus of claim 55, wherein the plurality of photovoltaic cells are bundled.

57. The apparatus of claim 52 comprising an array of pixels.

58. The apparatus of claim 57, wherein each pixel of the array comprises a plurality of photovoltaic cells.

59. The apparatus of claim 52, wherein the apparatus is flexible.

60. The apparatus of claim 52, wherein the apparatus is a solar collector.
61. The apparatus of claim 60, wherein the solar collector has a conversion efficiency greater than 6%.
- 5 62. A method for converting photonic energy into electrical energy comprising:
receiving radiation along the longitudinal axis of an optical fiber;
transmitting the radiation into at least one photosensitive organic layer through a
radiation transmissive electrode surrounding the optical fiber;
generating excitons in the organic layer; and
separating the excitons into electrons and holes at a heterojunction in the organic
10 layer.
63. The method of claim 62, wherein the optical fiber is a glass optical fiber, quartz
optical fiber, or a plastic optical fiber.
64. The method of claim 62, wherein the radiation transmissive electrode comprises a
radiation transmissive conducting oxide.
- 15 65. The method of claim 64, wherein the radiation transmissive conducting oxide
comprises indium tin oxide, gallium indium tin oxide, or zinc indium tin oxide.
66. The method of claim 62, wherein the heterojunction comprises a donor material and
an acceptor material.
67. The method of claim 66, wherein the donor material comprises a polymeric phase and
20 the acceptor material comprises a nanoparticle phase.
68. The method of claim 62, wherein the heterojunction comprises a plurality of bulk
heterojunctions.
69. The method of claim 62, wherein the radiation comprises visible radiation.
70. The method of claim 62, wherein the radiation comprises infrared radiation.
- 25 71. The method of claim 62 further comprising providing at least one scattering agent in
the optical fiber.
72. The method of claim 62 further comprising providing at least one upconverter in the
optical fiber.
73. The method of claim 62, further comprising removing the electrons into an external
30 circuit.
74. A photovoltaic cell comprising:
a fiber core;
a radiation transmissive first electrode surrounding the fiber core;

at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode; and

a second electrode surrounding the organic layer and electrically connected to the organic layer.

5 75. The photovoltaic cell of claim 74 having a conversion efficiency greater than 6%

76. The photovoltaic cell of claim 74, have a conversion efficiency greater than 10%.

77. A solar cell comprising:

at least one pixel comprising at least one photovoltaic cell, the photovoltaic cell comprising:

10 a fiber core;

a radiation transmissive first electrode surrounding the fiber core;

at least one photosensitive organic layer surrounding the first electrode and electrically connected to the first electrode; and

15 a second electrode surrounding the organic layer and electrically connected to the organic layer.

78. The solar cell of claim 77 having a conversion efficiency greater than 6%.

79. An apparatus comprising:

a fiber core;

a radiation transmissive first electrode surrounding the fiber core;

20 a plurality of photosensitive organic layers surrounding the first electrode and electrically connected to the first electrode; and

a second electrode surrounding the plurality of organic layers and electrically connected to the plurality of organic layers.

25 80. The apparatus of claim 79, further comprising at least one buffer layer disposed between the plurality of photosensitive organic layers.

81. The apparatus of claim 80, wherein the at least one buffer layer comprises a charge transfer layer.

82. The apparatus of claim 81, wherein the charge transfer layer comprises an exciton blocking layer.

30 83. An apparatus comprising:

a fiber core;

a plurality of photosensitive regions disposed along the longitudinal axis of the fiber core, each photosensitive region comprising:

a radiation transmissive first electrode surrounding the fiber core;

at least one photosensitive organic layer surrounding the first electrode and;
a second electrode surrounding the organic layer and electrically connected to
the organic layer.

84. The apparatus of claim 83, wherein the fiber core comprises an optical fiber.

- 5 85. A method for converting electromagnetic energy in the form of waves into electrical energy, the method comprising: receiving an electromagnetic wave; and guiding the electromagnetic wave to transmit radiation into a photosensitive layer.